

## MNE 2009 Programme Frame

Mon 28 Sep		Tue 29 Sep			Wed 30 Sep			Thu 1 Oct				
09:00 - 12:30 <b>4 Short courses</b>		08:00 Welcome coffee			08:00 Welcome coffee			08:00 Welcome coffee				
		08:30 Welcome address			08:30 - 09:10 <b>Plenary III: Hans Pfeiffer</b>			08:30 - 09:10 <b>Plenary V: Franz Laermer</b>				
		08:50 - 09:30 <b>Plenary I: Luc van den Hove</b>										
		09:30 - 10:10 <b>Plenary II: Tobias Kippenberg</b>			09:10 - 09:50 <b>Plenary IV: Chad Mirkin</b>			09:10 - 09:50 <b>Plenary VI: Lars Samuelson</b>				
		10:10 - 10:40 <b>Coffee break</b>			09:50 - 10:20 <b>Coffee break</b>			09:50 - 10:20 <b>Coffee break</b>				
12:30 - 13:30 <b>Lunch</b>		10:40-12:10 <b>Litho graphy materials</b>	10:40-12:10 <b>Nano photonics</b>	10:40-12:10 <b>Micro systems I</b>	10:20-12:10 <b>Nano imprint I</b>	10:20-12:10 <b>Nano patterning &amp; metro logy</b>	10:20-12:10 <b>Micro systems II</b>	10:20-12:10 <b>Maskless litho graphy II</b>	10:20-12:10 <b>Photonic crystals</b>	10:20-12:10 <b>Integrated MEMS</b>		
		12:10 - 13:40 <b>Lunch &amp; networking</b>			12:10 - 13:40 <b>Lunch &amp; networking</b>			12:10 - 13:40 <b>Lunch &amp; networking</b>				
		13:40-15:30 <b>Optical litho graphy</b>	13:40-15:30 <b>Nano manu facturing</b>	13:40-15:30 <b>Nano sensors &amp; systems</b>	13:40-15:30 <b>Maskless litho graphy I</b>	13:40-15:30 <b>Top down nano manu facturing</b>	13:40-15:30 <b>MEMS materials &amp; techno logy</b>	13:40-15:30 <b>Nano imprint II</b>	13:40-15:30 <b>Nano wires &amp; nanowire devices</b>	13:40-15:30 <b>Nano fluidics</b>		
		15:30 - 18:00 <b>Poster Session I (odd numbers) Reception</b>			15:30 - 18:00 <b>Poster Session II (even numbers) Reception</b>			15:30 - 16:00 <b>Coffee break</b>				
		17:00-20:00 <b>Exhibition</b>								16:00-17:30 <b>Cell interfaces</b>	16:00-17:30 <b>Carbon nanotube &amp; diamond application</b>	16:00-17:30 <b>NEMS</b>
							Closing	Closing	Closing			
				19:30 <b>Conference dinner</b>								
18:30-20:00 <b>Welcome reception</b>												